

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

**Priority** Application Serial No. ....09/602,381  
**Priority** Filing Date ..... June 22, 2000  
Inventor.....John T. Moore  
Assignee.....Micron Technology, Inc.  
**Priority** Group Art Unit .....2815  
**Priority** Examiner ..... Wojciechowicz  
Attorney's Docket No. ....MI22-2438  
Title: (As amended) Methods of Forming Dielectric Materials and Methods of Processing  
Semiconductor Substrates

**PRELIMINARY AMENDMENT**

To: MS Patent Application  
Commissioner for Patents  
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**AMENDMENTS**

**Introductory Comments**

Applicant amends the application and remarks as follows.